

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of ) Examiner: William K. Cheung  
: :  
Koichi Sato, et al. ) Group Art Unit: 1796  
: :  
Appln. No.: 10/519,914 ) Confirmation No.: 3004  
: :  
Filed: January 3, 2005 )  
: :  
For: BLOCK POLYMER COMPOUND, )  
POLYMER COMPOSITION CONTAINING :  
THE SAME, IMAGE FORMING METHOD ) October 23, 2009  
AND IMAGE FORMING APPARATUS :  
UTILIZING THE SAME )

**Mail Stop Issue Fee**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

COMMENTS ON STATEMENT OF REASONS FOR ALLOWANCE

Sir:

Applicants are in receipt of a Notice of Allowance dated October 1, 2009, in the above-referenced application. The Issue Fee is due on or before January 1, 2010, and is being paid concurrently herewith.

Applicants respectfully traverse the Reasons for Allowance set forth in the October 1, 2009 Notice of Allowability on the grounds that whereas the Reasons refer to “the triblock copolymers”, the claims do not use this exact phrase, but instead are believed to be allowable for the language that they do contain (including, *inter alia*, “comprising block segments A, B, and C”).

Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should continue to be directed to our address listed below.

Respectfully submitted,

/Daniel S. Glueck/  
Daniel S. Glueck  
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